

PAUL SCHERRER INSTITUT



FONDAZIONE  
BRUNO KESSLER



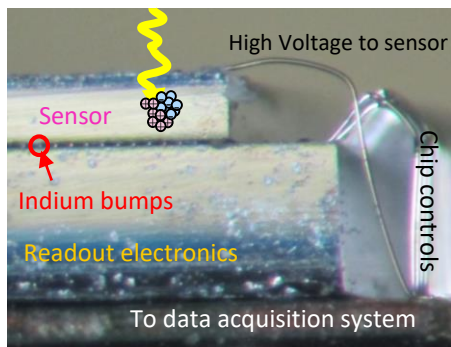
M.Carulla :: Photon Science Detector Group :: Paul Scherrer Institute

## Soft X-ray detection with single photon resolution using LGAD sensors

19-23 June 2023 :: High Precision X-Ray Measurements 2023 :: Frascati :: Italy

\* On behalf of Photon Science Detector group and FBK collaboration

Photon counting and charge integrating hybrid detectors: (Aldo's talk on Thursday at 12)



## Hybrid detectors:

- Material and process optimized separately

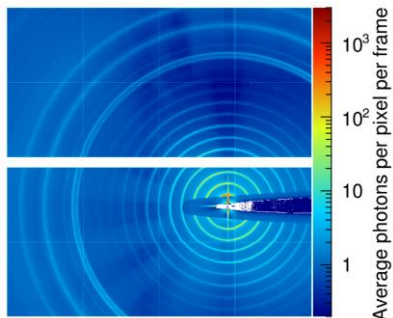
## Performance:

- **2-40 kframes/s**
- High dynamic range
- Large area
- High efficiency for  $E_{ph} > 1.2 \text{ keV}$

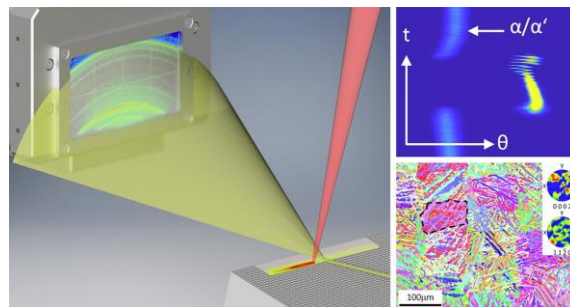


## Applications

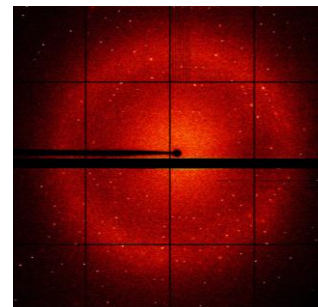
### Powder diffraction



### Operando diffraction



### Macromolecular crystallography



C.J. Milne *Appl. Sci.* **2017**, 7(7), 720;  
<https://doi.org/10.3390/app7070720>

Hocine et al.; *Materials today*, **2020**;  
<https://doi.org/10.1016/j.mattod.2019.10.001>

Leonarski et al.; *Nature methods*, **2018**;  
<https://doi.org/10.1038/s41592-018-0143-7>

# Single photon resolution of soft X-rays

## Soft X-rays (200 eV – 1.2 keV):

- Energy between K-edges of C and O: polymers, organic electronics, aerosols, and biological materials
- L-edges of 3d transition metals: cuprate, Mott insulators and ferromagnetic and antiferromagnetic materials

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Our goal is to optimize the sensors of our hybrid detector to achieve single photon resolution for soft X-rays

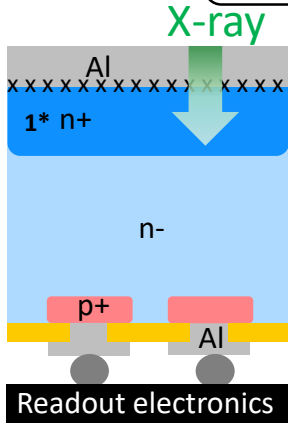
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Low quantum efficiency



1. Recombination in the n+ region,  
 $L_h = 200 \text{ nm}$

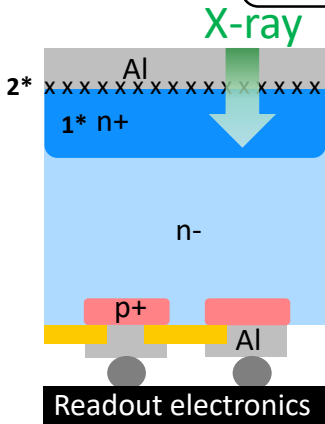
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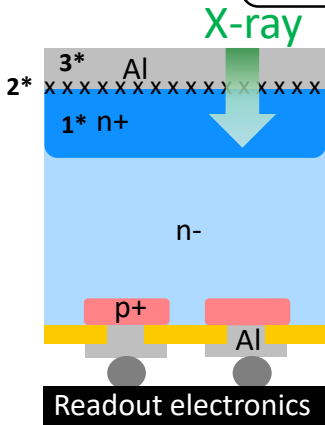
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3. Absorption in the surface layers

Reduce losses in the entrance window

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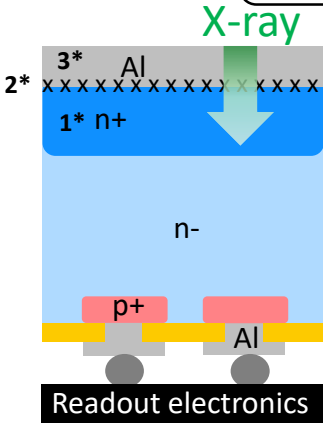
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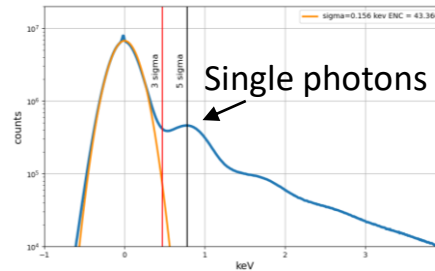
Our goal is to optimize the sensors of our hybrid detector to achieve single photon resolution for soft X-rays

Low quantum efficiency

Low signal-to-noise ration



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3. Absorption in the surface layers



V. Hinger et al 2022 JINST 17 C09027

- At least a SNR of 5 is required to achieve single photon resolution
- Just 55 e-h pairs are created for 200 eV photons giving a SNR of 1.3

Reduce losses in the entrance window + Increase the signal by internal multiplication

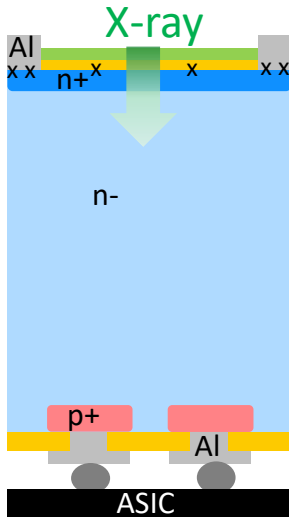


# Development of two technologies

In collaboration with Fondazione Bruno Kessler, we developed two optimized technologies for soft X-rays detection

## Entrance window technology

- Optimization of the n+
- Passivation of the surface

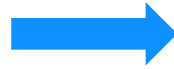


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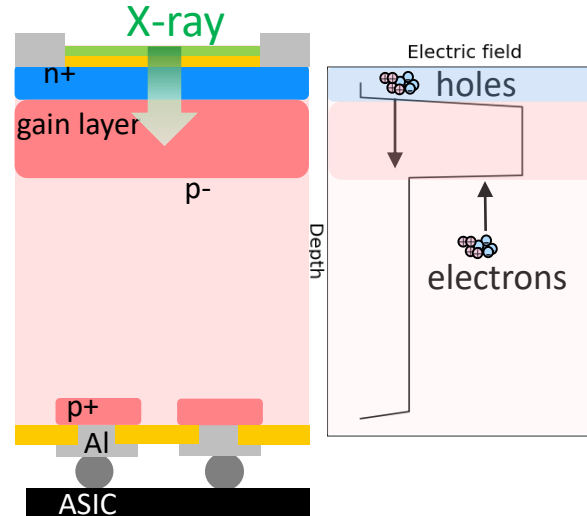
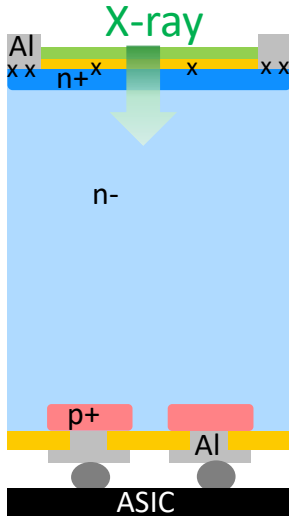
## Entrance window technology

- Optimization of the n+
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## Inverse low gain avalanche diode (iLGAD) technology

- Large electric field to trigger impact ionization

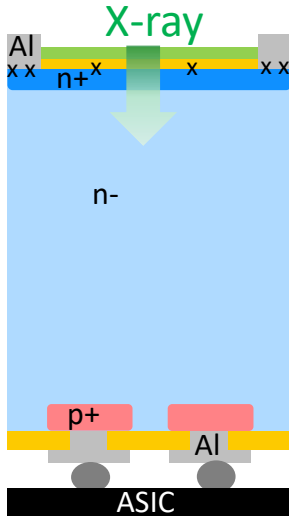


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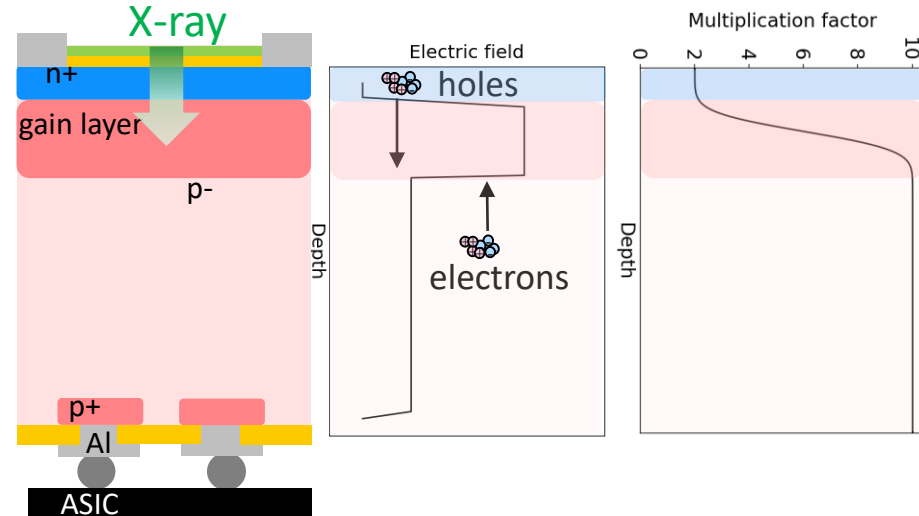
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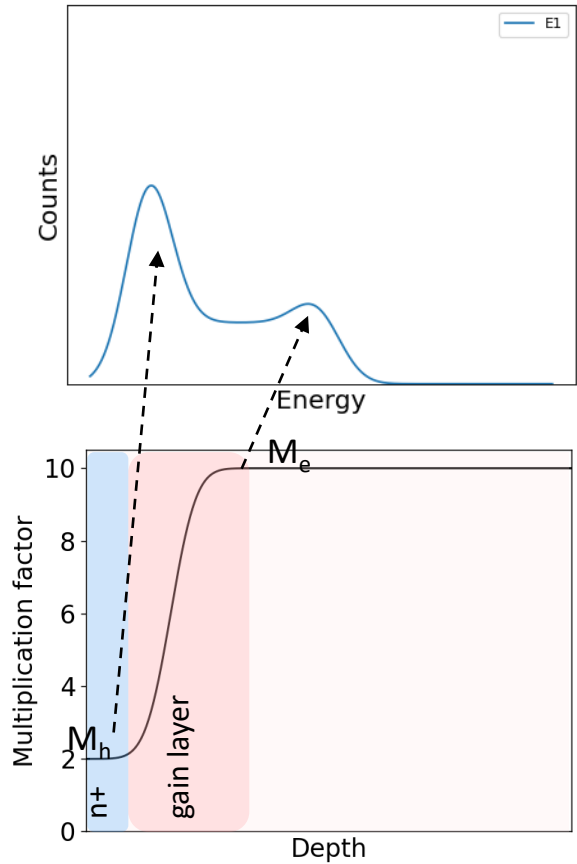
## Inverse low gain avalanche diode (iLGAD) technology

- Large electric field to trigger impact ionization
- Multiplication factor depends on absorption depth
- Optimization of the gain layer

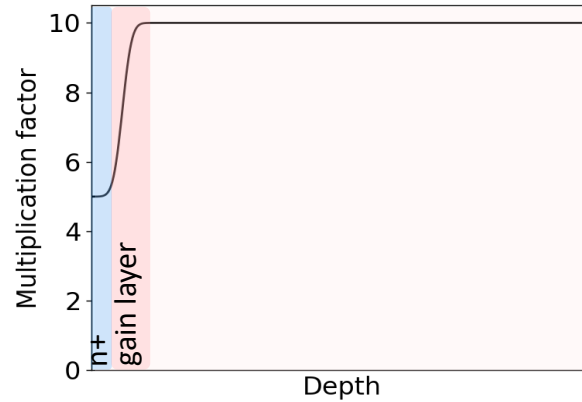


# Optimization gain layer

Standard



Ultra-shallow



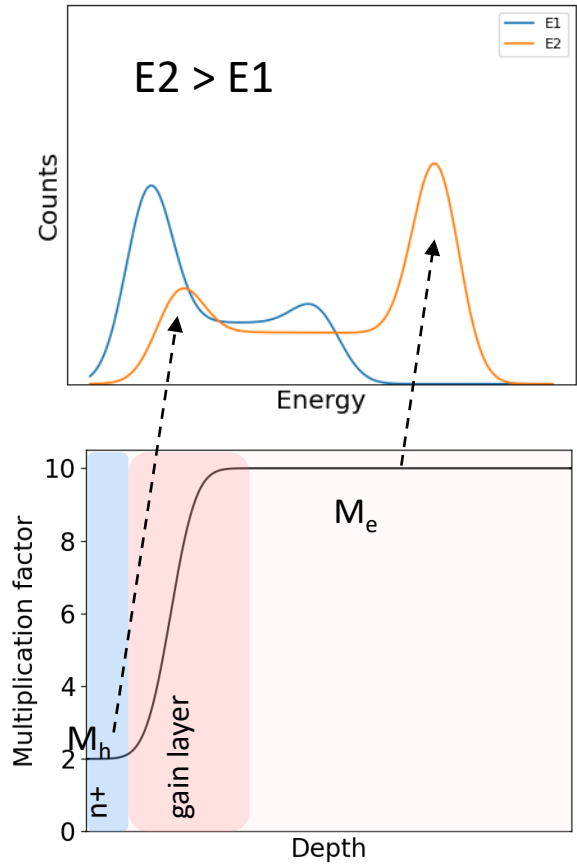
- Spectrum with two peaks

Standard design:

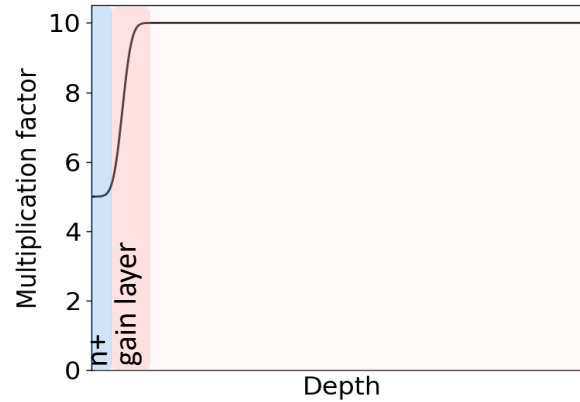
- At low energies high probability for hole started impact ionization

# Optimization gain layer

Standard



Ultra-shallow



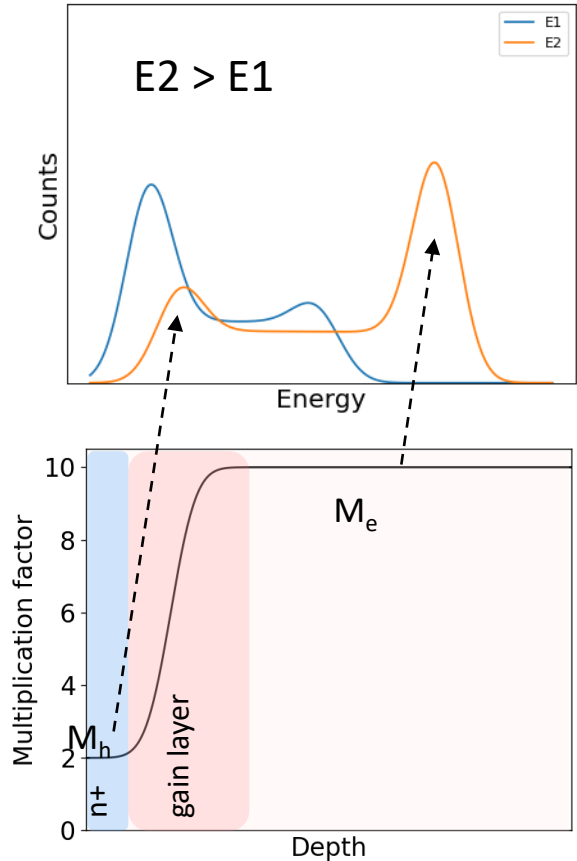
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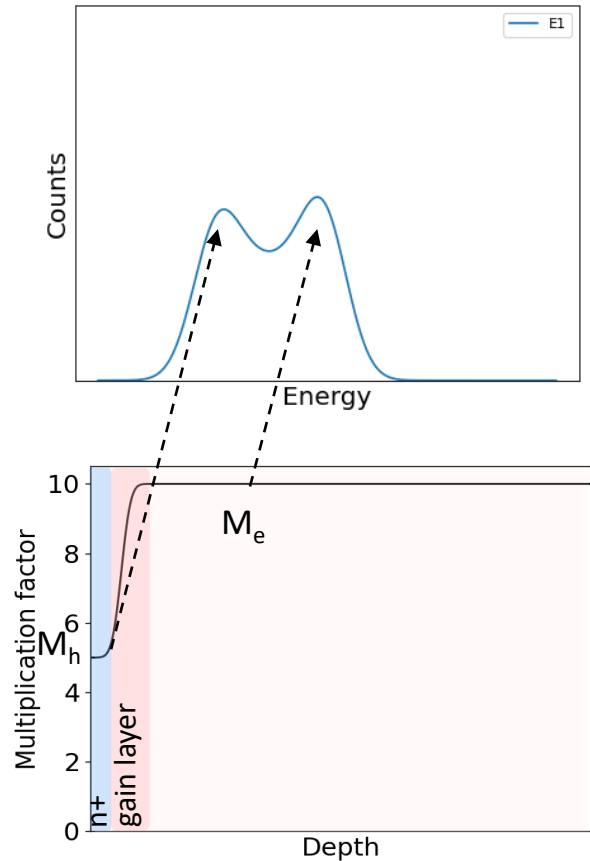
- At low energies high probability for hole started impact ionization
- At high energies, high probability for electron started impact ionization

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Standard



Ultra-shallow



- Spectrum with two peaks

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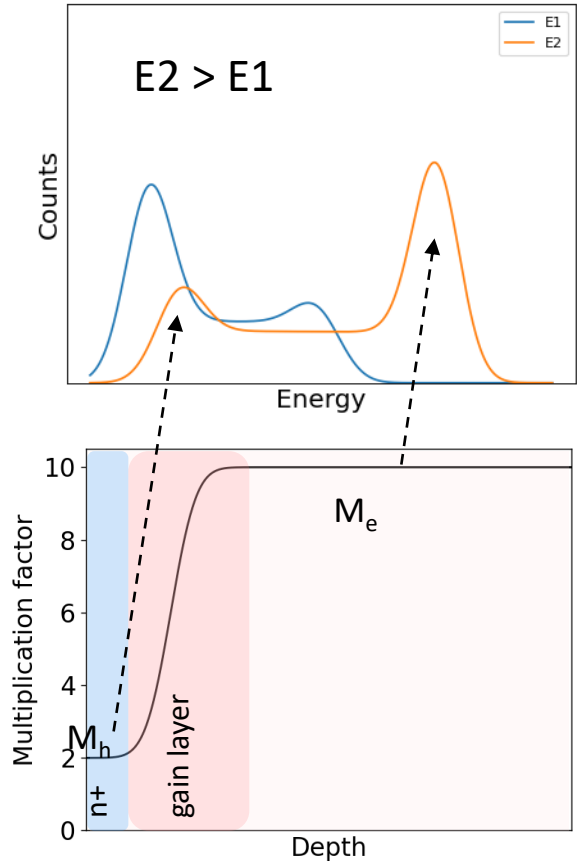
- At low energies high probability for hole started impact ionization.
- At high energies, high probability for electron started impact ionization.

Ultra-shallow design:

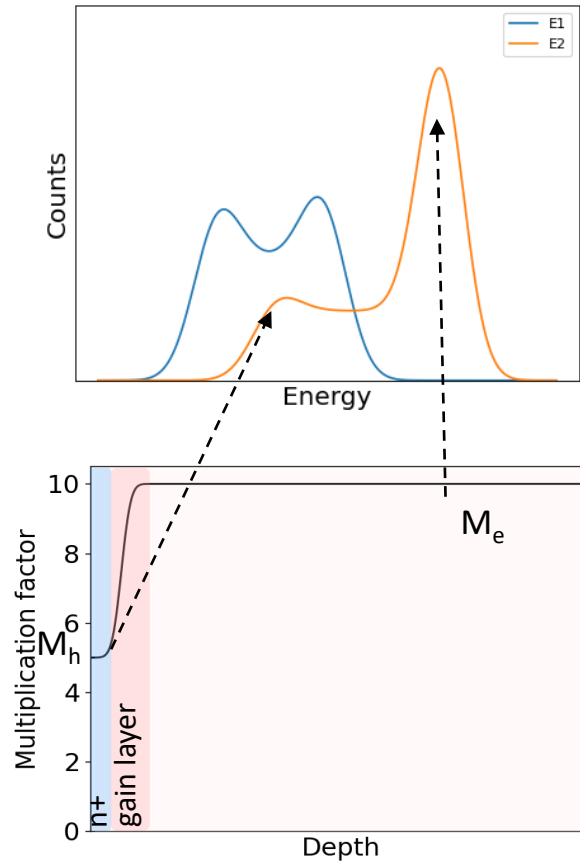
- At low energies the probability for electron started impact ionization is larger

# Optimization gain layer

Standard



Ultra-shallow



- Spectrum with two peaks

Standard design:

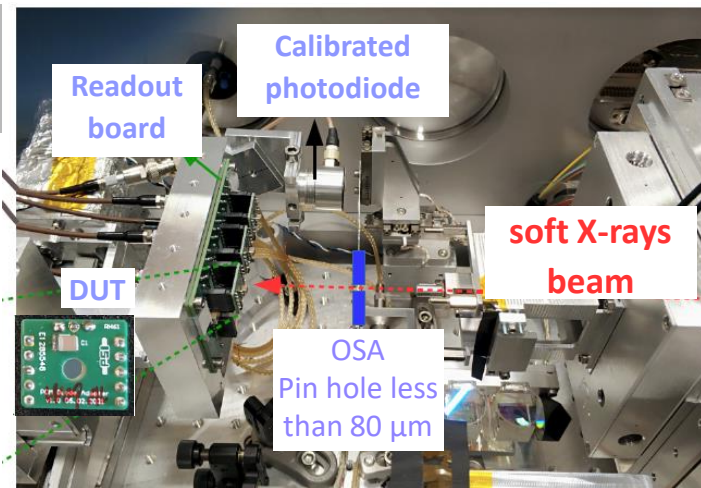
- At low energies high probability for hole started impact ionization.
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Ultra-shallow design:

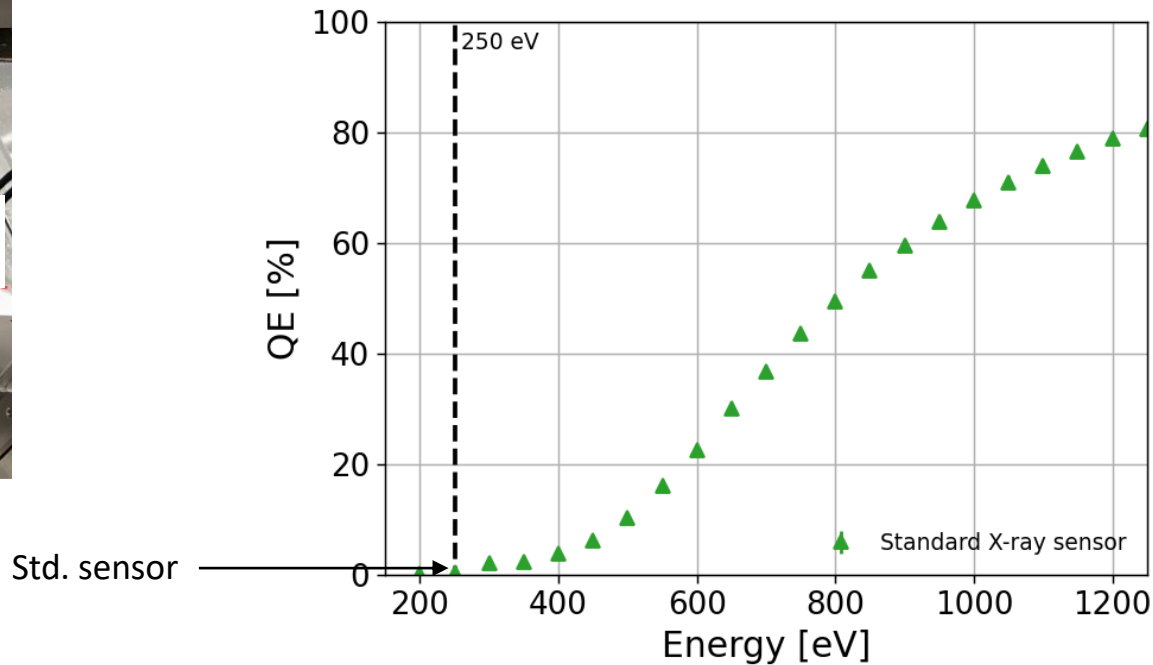
- At low energies the probability for hole started impact ionization is larger
- Design with high electric field in small region
- Difference between  $M_h$  and  $M_e$  is smaller.

# Efficiency of the entrance window technology

Setup at the Surface/Interfaces:Microscopy @ SLS



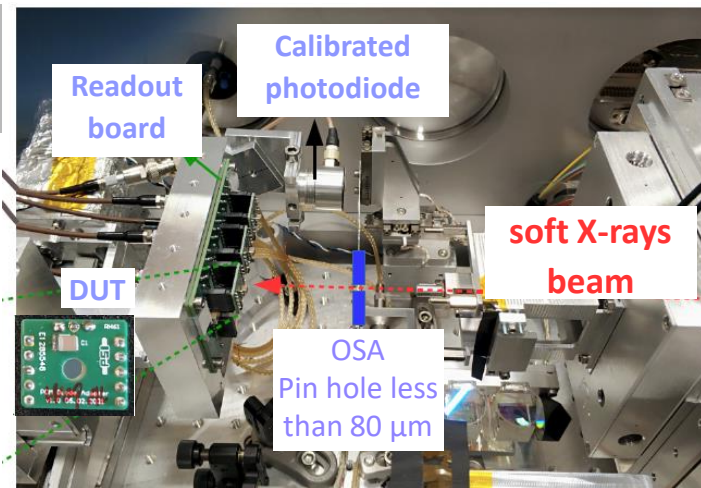
Quantum efficiency





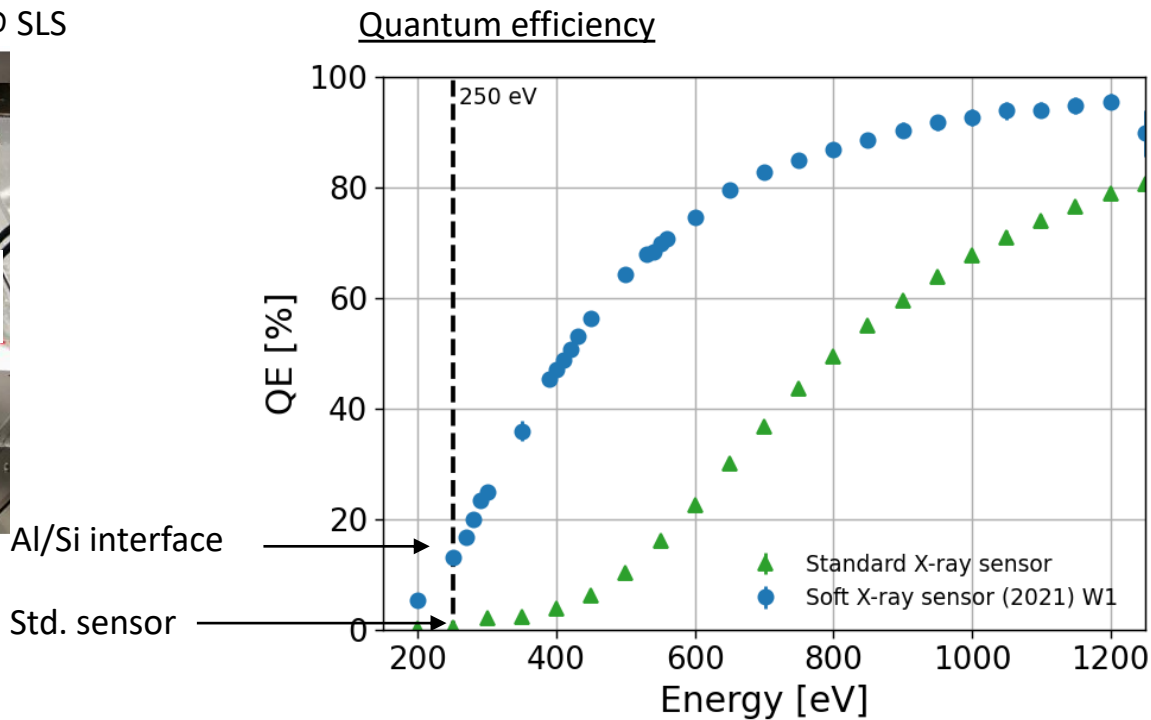
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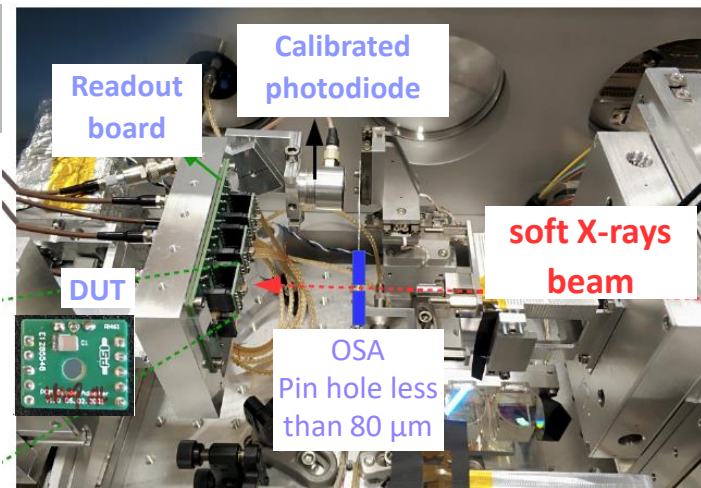
## Keys for high QE :

- Optimization of the n+



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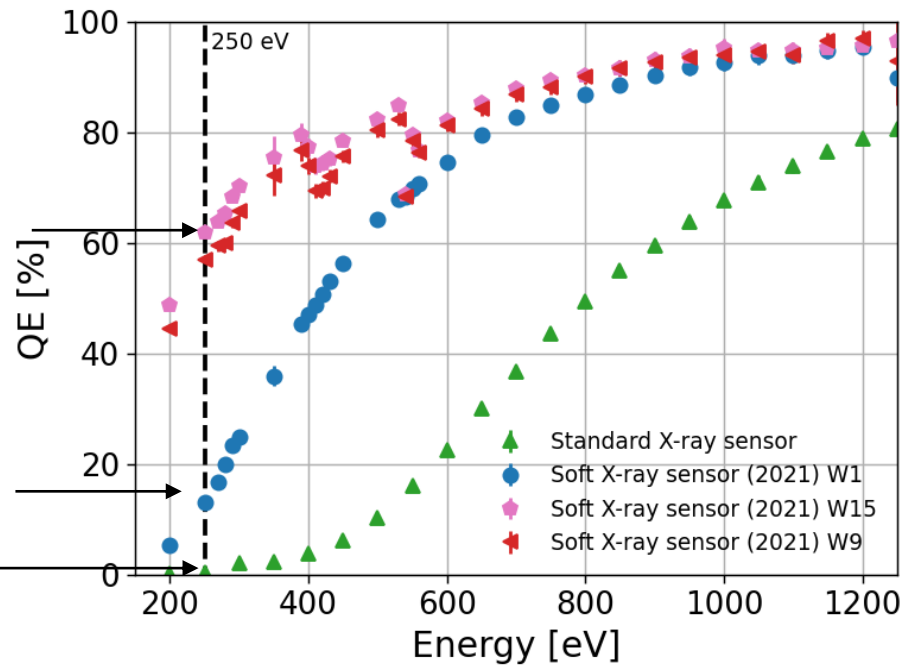


Passivated interface

Al/Si interface

Std. sensor

Quantum efficiency

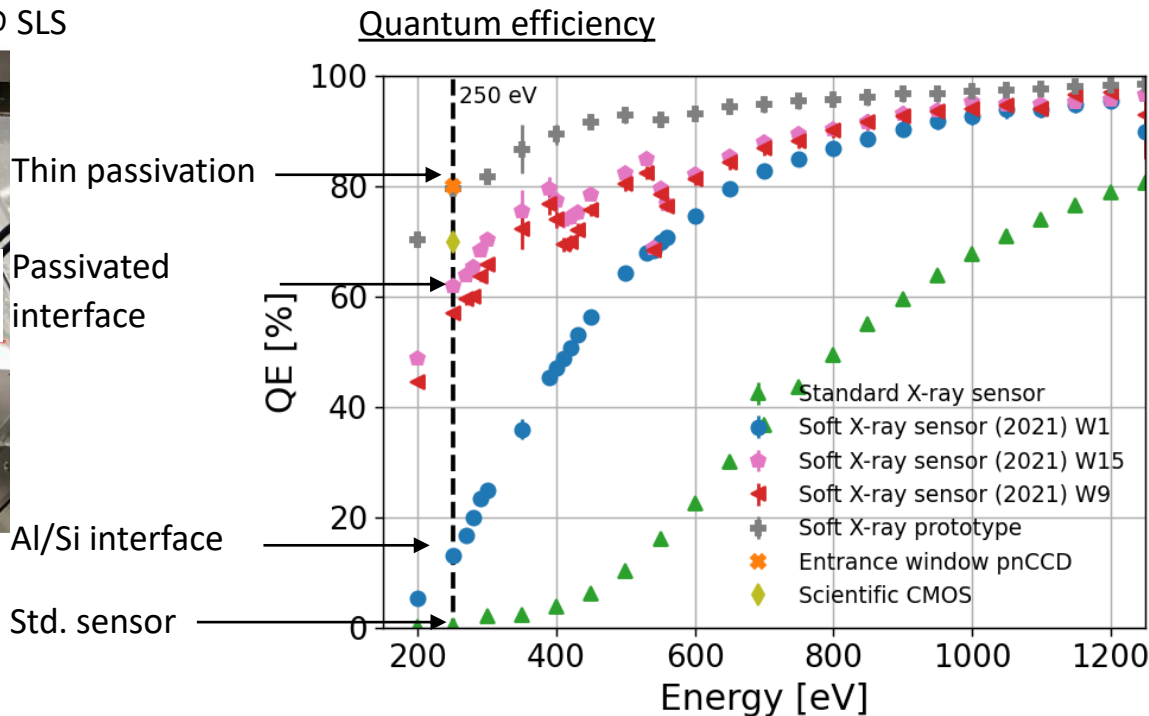
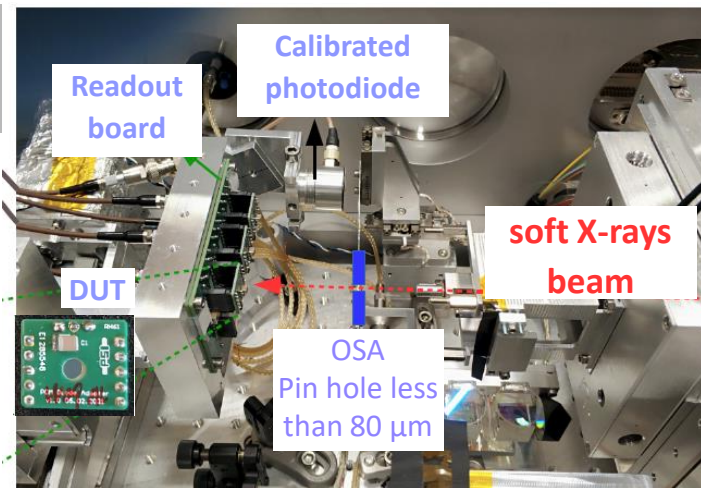


Keys for high QE :

- Optimization of the n+
- Surface passivation

# Efficiency of the entrance window technology

Setup at the Surface/Interfaces Microscopy @ SLS



## Keys for high QE :

- Optimization of the n+
- Surface passivation
- Reduction of the passivation layer

QE above 70 % of backside illuminated scientific CMOS\* and equal to 80 % of entrance window pnCCD\*\*

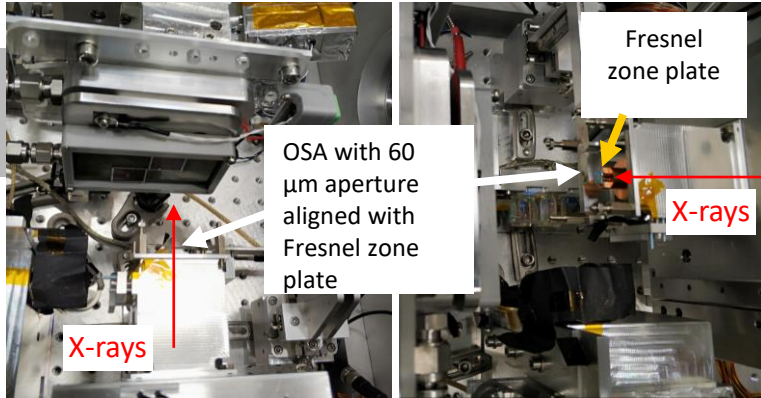
\*K. Desjardins, et al. 2020, J. Synchrotron Rad. 27, 1577–1589.

\*\* S. Send, et al. 2013, NIMA. 711, 132-142.

# Spectrum of iLGAD sensors

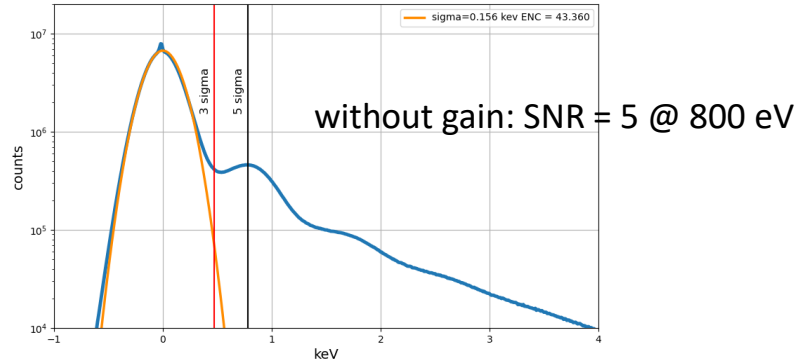
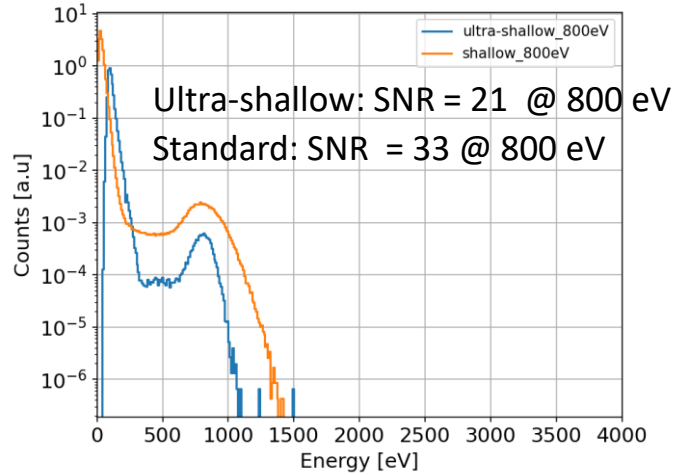
Setup at the Surface/Interfaces:Microscopy (SIM) beamline from SLS

- Two designs tested with JUNGFRAU : Standard & ultra-shallow



Front side picture

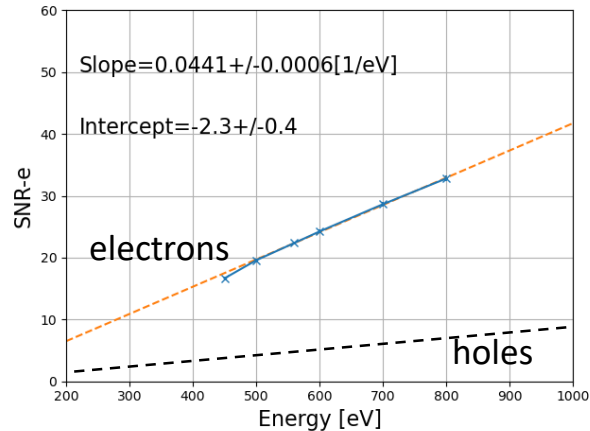
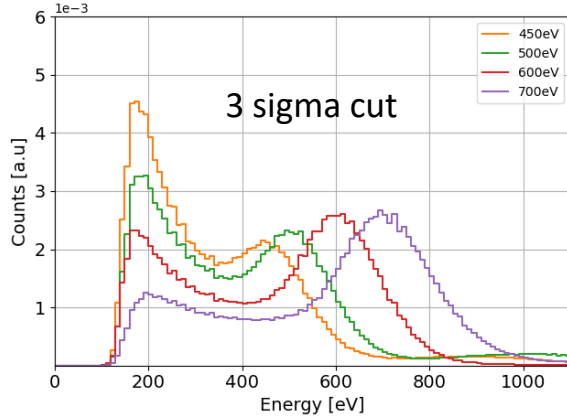
Right side picture



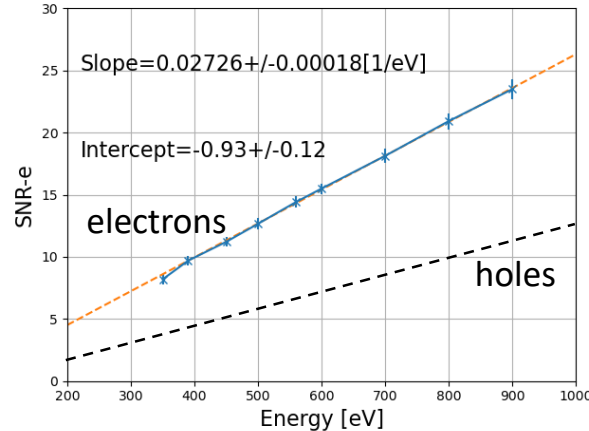
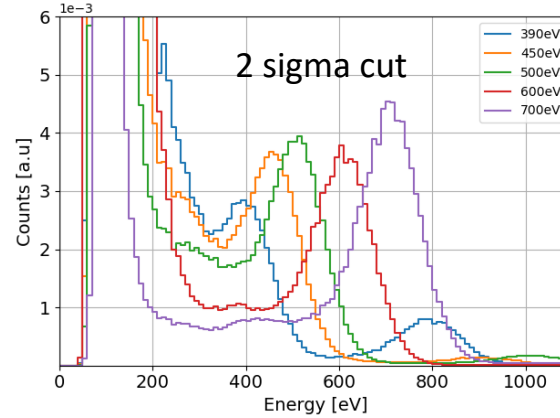
In comparison to the design without gain, the SNR has increased by a factor of 4 for ultra-shallow and 6 for the standard.

# Spectrum of iLGAD sensors

## Standard



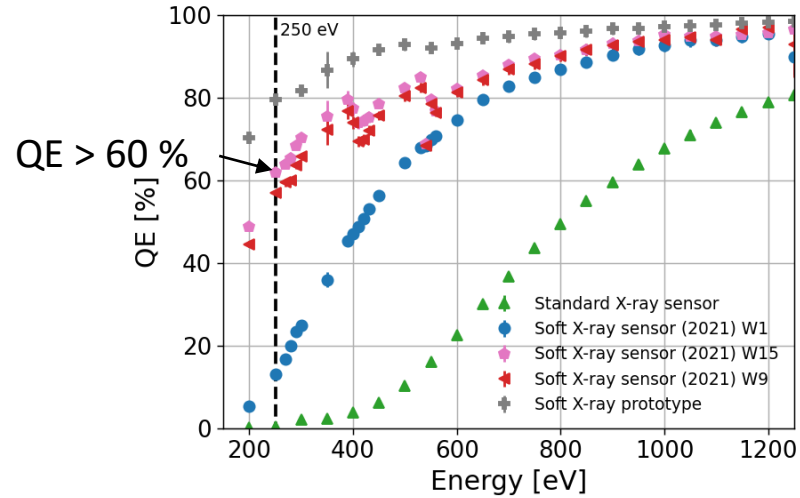
## Ultra-shallow



- Ultra-shallow design show low SNR due to the low gain in comparison to standard design
- Probability of electron started impact ionization for ultra-shallow design is larger than in standard
- The gain needs to be increased for detection of hole started impact ionization at 400 eV

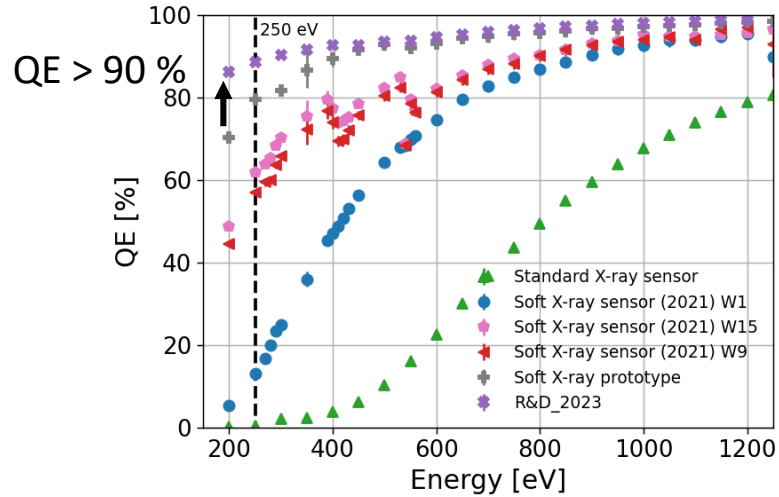
Can we obtain single photon resolution of soft X-rays with our fast detector system?

Optimization of the entrance window to reduce the losses in the surface and n+



Can we obtain single photon resolution of soft X-rays with our fast detector system?

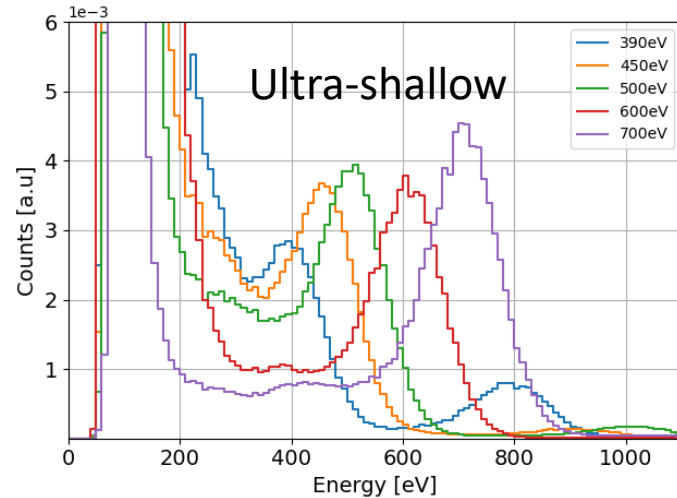
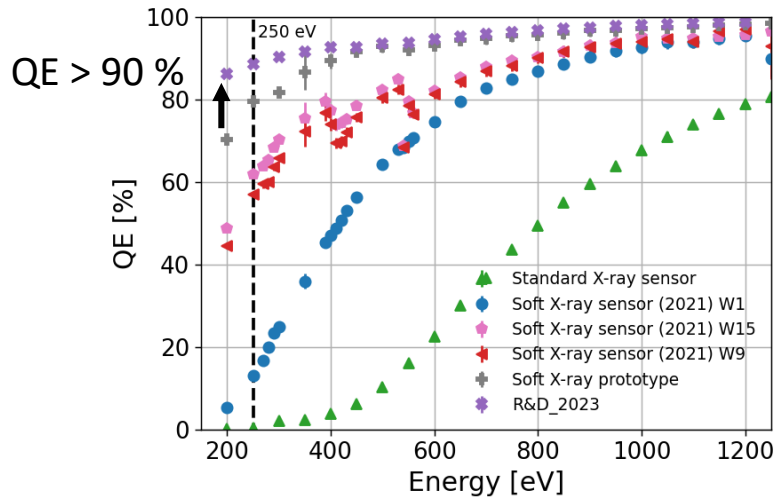
Optimization of the entrance window to reduce the losses in the surface and n+



Can we obtain single photon resolution of soft X-rays with our fast detector system?

Optimization of the entrance window to reduce the losses in the surface and n+

Optimization of the iLGAD design to increase the gain and the probability of photon absorption after the multiplication layer.



Combining the entrance window technology together with the iLGAD technology, our detector systems can detect 400 eV photons at high frame rates.



# Acknowledgement

## My thanks go to:

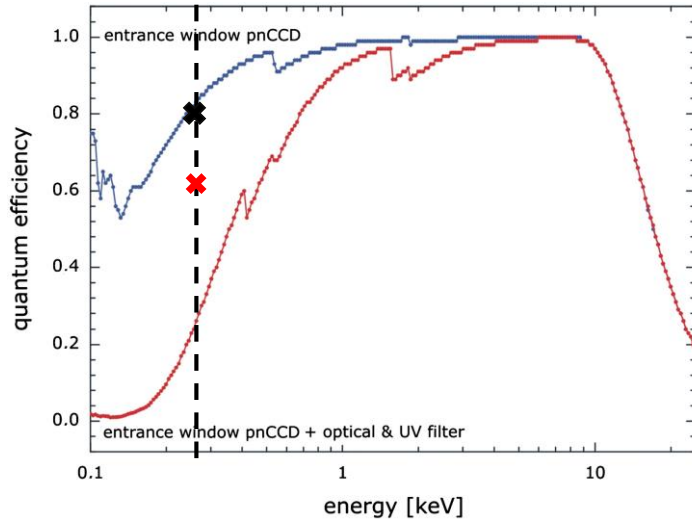
- M.Centis Vignali, F. Ficorella, G. Borghi, G. Paternoster, M.Boscardin, S. Ronchin and O. Hammad Ali from FBK
- K.Vogelsang and C.Wild from LXN
- A. Kleibert, J. Raabe and T. Butcher from the SLS.
- E. Razzoli from the SwissFEL.

## Photon Science Detector Group

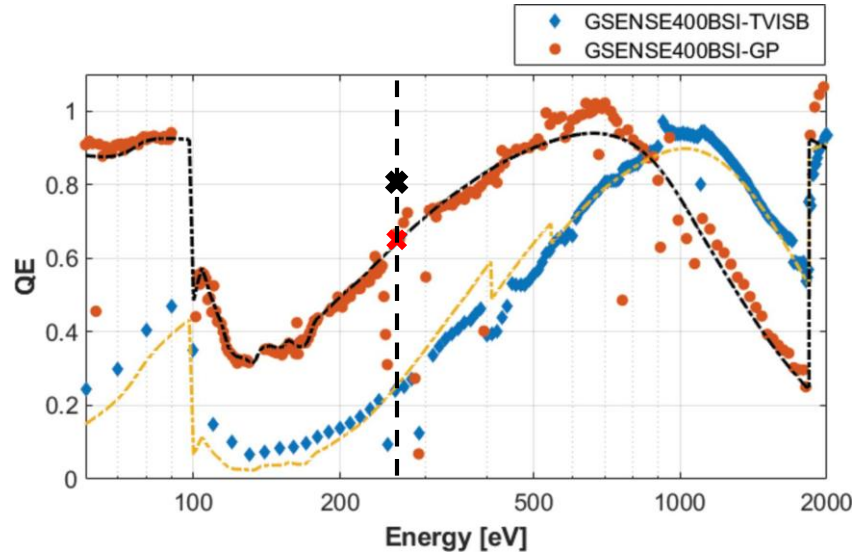
*Back:* J. Zhang, A. Mozzanica, T. King, D. Mezza, A. Bergamaschi, J. Heymes; *Middle:* E. Fröjdh, C. Lopez, M. Brückner, C. Ruder, B. Schmitt, K. Moustakas, D. Greiffenberg; *Front:* V. Hinger, D. Thattil, R. Dinapoli, S. Hasanaj, M. Carulla, S. Ebner; *Missing:* R. Barten, P. Kozlowski, F. Baruffaldi, K. Paton and X. Xie



# QE pnCCD and scientific CMOS

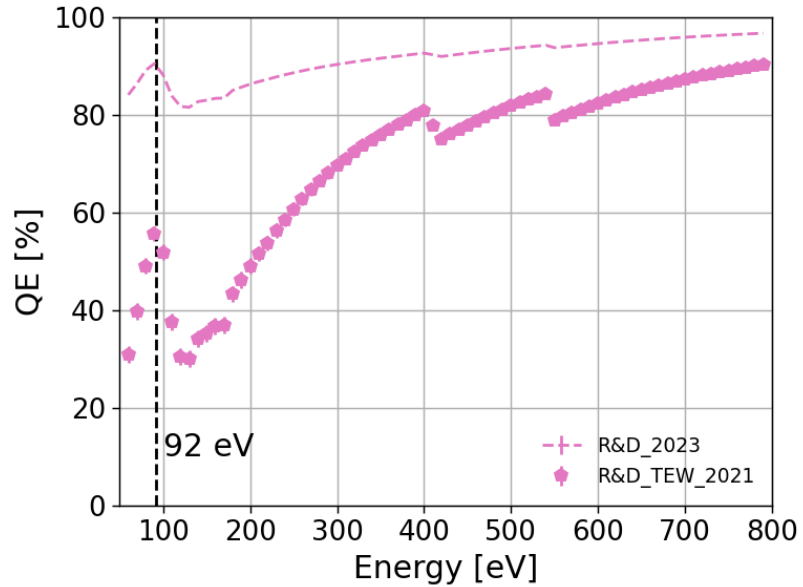


S. Send, et al. 2013, NIMA. 711, 132-142.



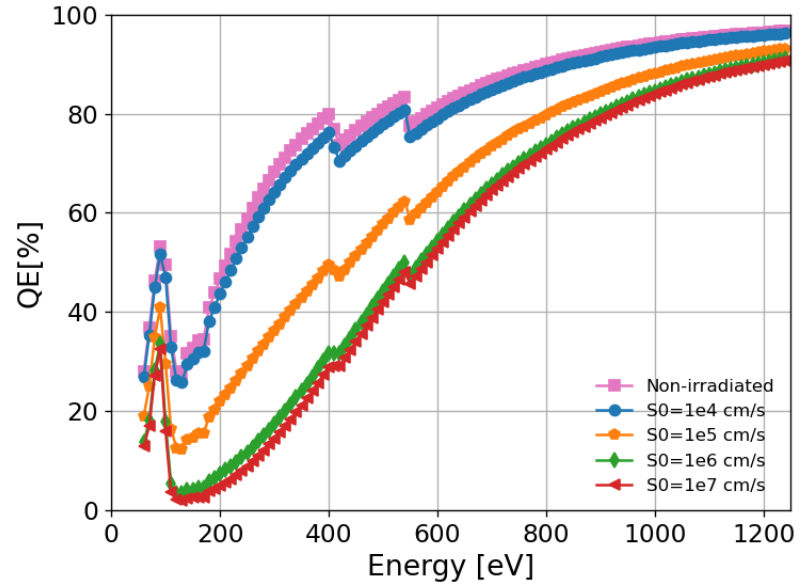
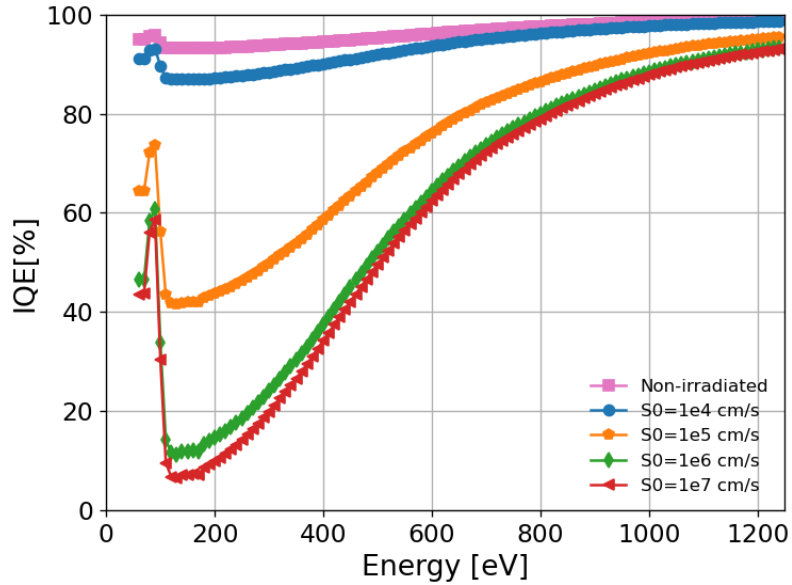
K. Desjardins, et al. 2020, J. Synchrotron Rad. 27, 1577-1589.

- ✘ QE > 0.62 current TEW and iLGAD sensors
- ✘ QE > 0.8 current prototype

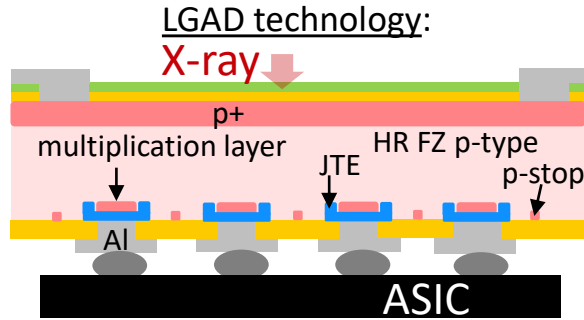


## IQE and QE after irradiation

S0 saturates to  $1e4$  cm/s

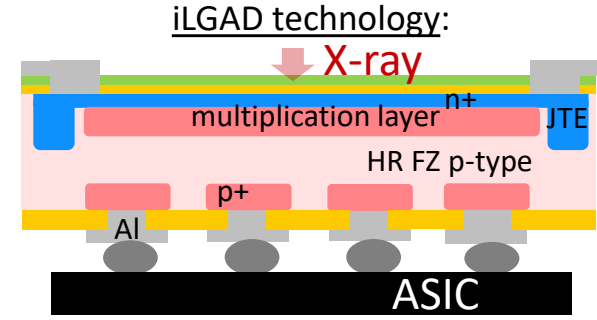


# LGAD vs iLGAD

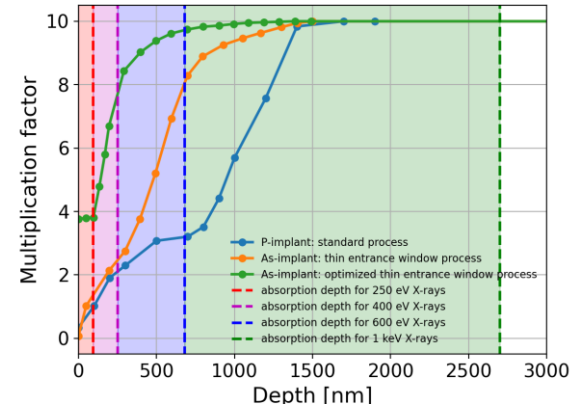
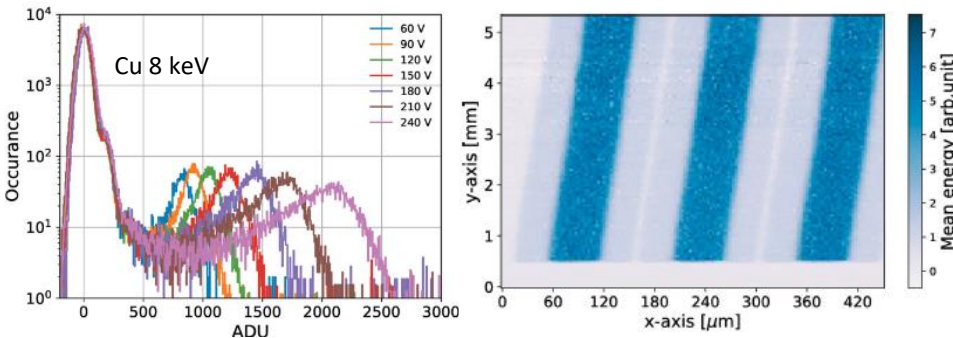


- ✓ SNR larger than 5
- ✓ Gain independent on the photon absorption depth

X Low fill factor

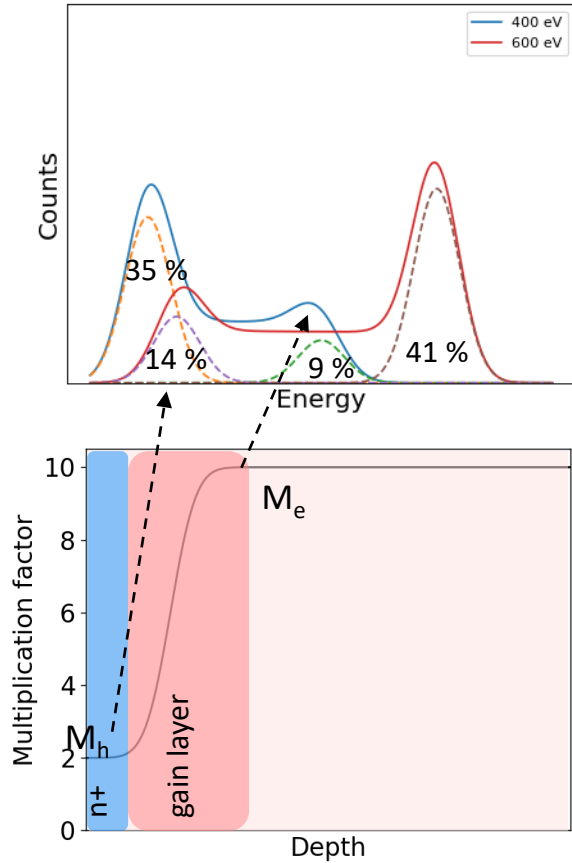


- ✓ SNR larger than 5
  - ✓ 100 % fill factor
- X Gain depends on photon absorption depth

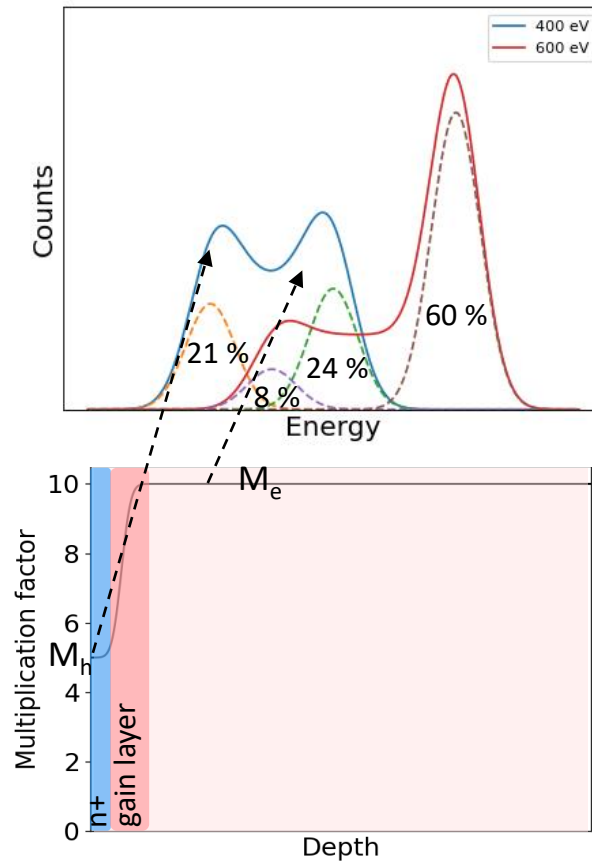


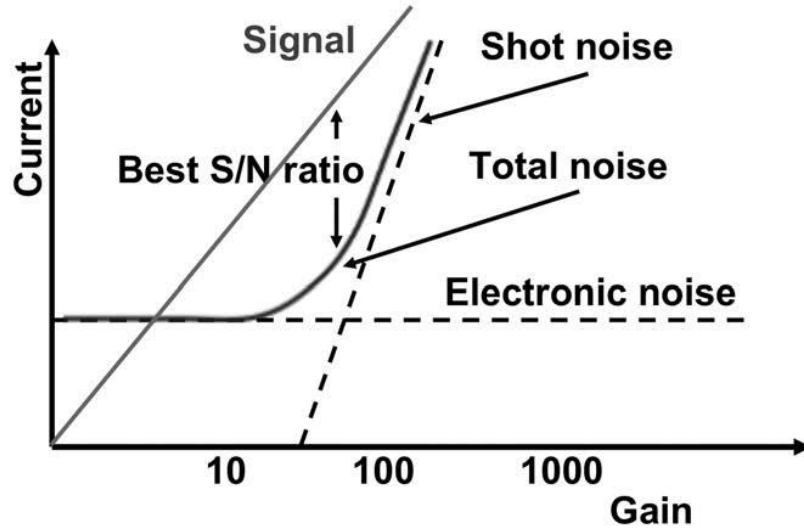
# Optimization gain layer

Standard



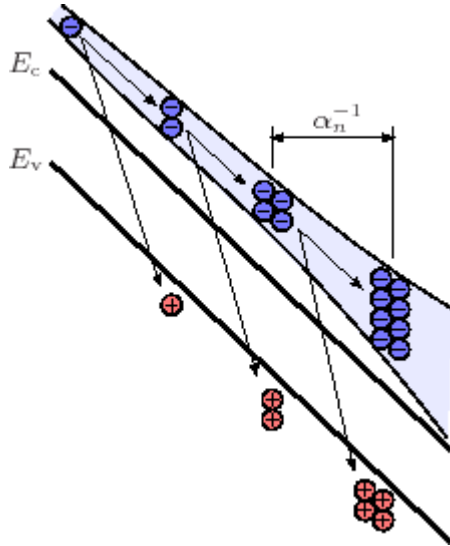
ultra-shallow





M.Ferrero et al. "An introduction to Ultra-Fast Silicon Detectors"

# Impact ionization

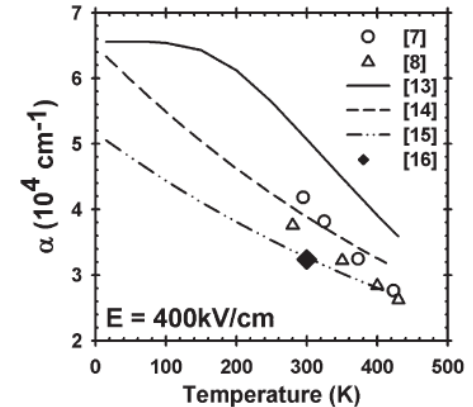
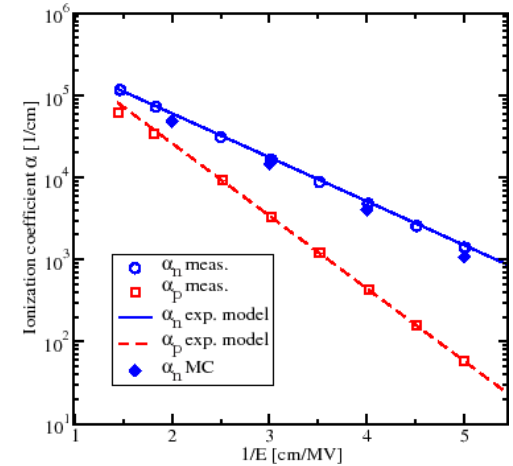


Relationship with electric field and temperature:

$$\alpha_v = \alpha_v^\infty \cdot \exp\left(-\left(\frac{C_v + D_v T}{E}\right)^{\beta_v}\right)$$

Pure electron started impact ionization

O. Triebel, "Reliability Issues in High-Voltage Semiconductor Devices"



D. Massey, "Temperature dependence of impact ionization in submicrometer silicon devices"